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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
09/757,965	01/10/2001	Tak Hung Ning	YOR920000588US2	9386
. 7590 12/22/2003			EXAMINER	
Robert M. Trepp Intellectual Property Law Dept. IBM Corporation P.O. Box 218 Yorktown Heights, NY 10598			TRAN, THIEN F	
			ART UNIT	PAPER NUMBER
			2811	
			DATE MAILED: 12/22/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

		\mathcal{K}^{\wedge}			
	Application No.	Applicant(s)			
Office Action Occasions	09/757,965	NING, TAK HUNG			
Office Action Summary	Examiner	Art Unit			
	Thien F Tran	2811			
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with the	correspondence address			
A SHORTENED STATUTORY PERIOD FOR REPL' THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a replication of the period for reply is specified above, the maximum statutory period of Failure to reply within the set or extended period for reply will, by statute any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b). Status	36(a). In no event, however, may a reply be to within the statutory minimum of thirty (30) do will apply and will expire SIX (6) MONTHS from the application to become ABANDON.	timely filed ays will be considered timely. m the mailing date of this communication. IED (35 U.S.C. § 133).			
1) Responsive to communication(s) filed on 14 N	lovember 2003.				
2a)⊠ This action is FINAL . 2b)☐ This	action is non-final.				
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims					
4) ☐ Claim(s) 1-22 is/are pending in the application 4a) Of the above claim(s) 3,4 and 6-22 is/are w 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 1,2 and 5 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and/o	vithdrawn from consideration.				
Application Papers	·				
9)☐ The specification is objected to by the Examine 10)☐ The drawing(s) filed on is/are: a)☐ acc		e Examiner.			
Applicant may not request that any objection to the	drawing(s) be held in abeyance. S	ee 37 CFR 1.85(a).			
Replacement drawing sheet(s) including the correct	, , , , , , , , , , , , , , , , , , , ,	•			
11) The oath or declaration is objected to by the Ex	caminer. Note the attached Office	e Action or form PTO-152.			
Priority under 35 U.S.C. §§ 119 and 120					
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority document 2. Certified copies of the priority document 3. Copies of the certified copies of the priority document application from the International Bureau * See the attached detailed Office action for a list 13) Acknowledgment is made of a claim for domesti since a specific reference was included in the first 37 CFR 1.78. a) The translation of the foreign language pro 14) Acknowledgment is made of a claim for domesti reference was included in the first contents of the	s have been received. s have been received in Applica rity documents have been receiv u (PCT Rule 17.2(a)). of the certified copies not receiv ic priority under 35 U.S.C. § 119 st sentence of the specification of existing application has been received priority under 35 U.S.C. §§ 12	ation No ved in this National Stage ved. 0(e) (to a provisional application) or in an Application Data Sheet. eceived. 20 and/or 121 since a specific			
reference was included in the first sentence of the	ie specification of in an Applicat	ion Data Sneet, 37 CFR 1.78.			
Attachment(s)	_				
Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449) Paper No(s) _	5) Notice of Informal	ry (PTO-413) Paper No(s) Patent Application (PTO-152)			

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DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1 and 2 are rejected under 35 U.S.C. 102(b) as being anticipated by Mahnkopf et al. (USPN 5,587,599).

Mahnkopf et al. discloses the claimed bipolar transistor (Fig. 5) comprising a substrate, an insulating layer over said substrate, a first single crystal semiconductor layer positioned over said insulating layer having a lightly doped region 22 of a first type (n type) and at least one contiguous heavily doped region 10 of said first type, said lightly doped region and said at least one contiguous heavily doped region functioning as a collector, wherein said lightly doped region 22 is directly underneath a base 21, a second patterned semiconductor layer 21 of a second type formed over said lightly doped region of said first semiconductor layer to function as the base, and a third patterned semiconductor layer (5, 8) of said first type positioned over said second semiconductor layer to function as an emitter, said lightly doped region 22 of n-type having a doping concentration that the collector region 22 is essentially completely depleted of mobile charge through said first semiconductor layer to said insulating layer when the electrical potentials required for the intended operating mode of the transistor are applied (see col. 6, lines 30-35).

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Regarding claim 2, the first single crystal semiconductor layer 22 has a thickness in the range from 30 to 1000 nanometers.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claim 5 is rejected under 35 U.S.C. 103(a) as being unpatentable over Mahnkopf et al. (USPN 5,587,599) in view of Imai (USPN 5,506,427).

Mahnkopf et al. as described above does not explicitly disclose the second patterned semiconductor layer 21 (the base layer) being a silicon germanium alloy. Imai discloses a bipolar transistor in which the base is formed of silicon germanium alloy. It would have been obvious to a person having ordinary skill in the art at the time the invention was made to form the base layer 21 of Mahnkopf et al. of silicon germanium alloy to enhance the efficiency of carrier injection from the emitter into the base.

Response to Arguments

Applicant's arguments filed 11/14/2003 have been fully considered but they are not persuasive. Mahnkopf clearly discloses the same structure as claimed wherein the collector region 22 is provided with a light doping concentration so that the collector region 22 is fully depleted of charge carriers (col. 6, lines 30-35); and the lightly doped region 22 is directly underneath a base 21.

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Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Thien F Tran whose telephone number is (703) 308-4108. The examiner can normally be reached on 8:30AM - 5:00PM Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Eddie C Lee can be reached on (703) 308-1690. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9318.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

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December 16, 2003

This F Mars

Thien F Tran
Primary Examiner

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